

# Electrospray printing of graphene layers for chemiresistive gas sensors

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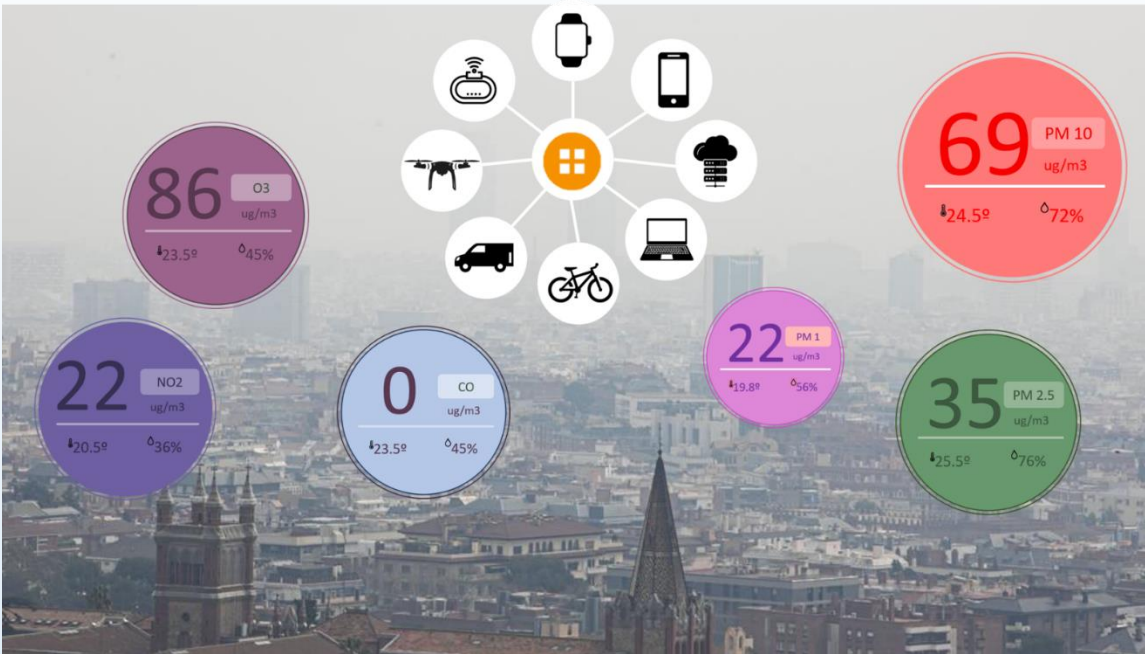
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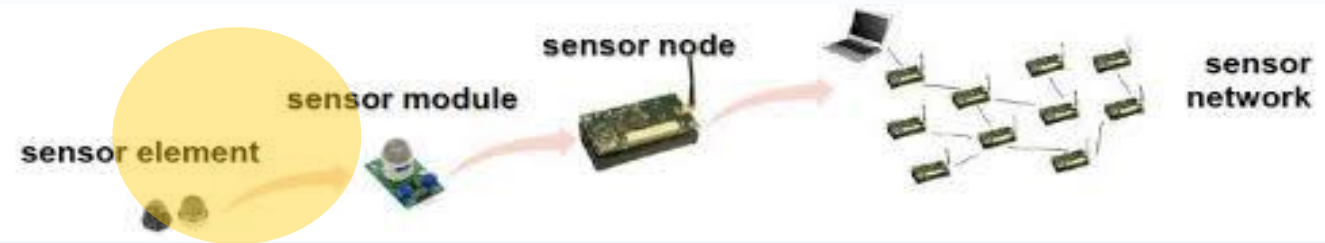
# 1. MOTIVATION (I)

## Wireless Sensor Networks (WSN)

### Air Quality Monitoring (AQM)



**Low cost**      **Low power**      **High resolution (x, t)**  
**Distributed**      **Massive**      **Ubiquitous...**

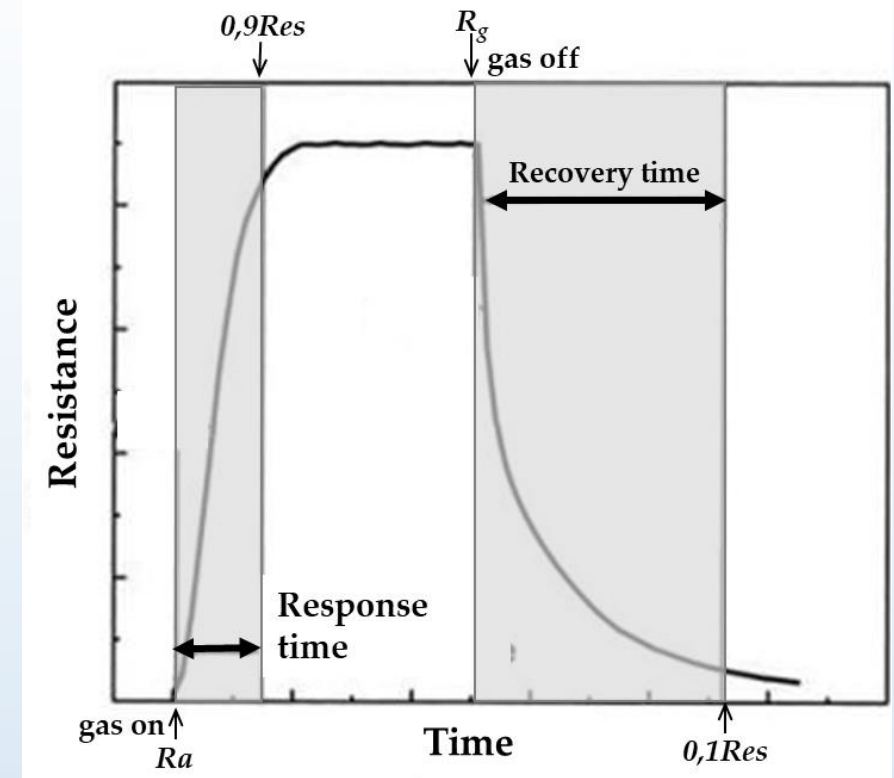
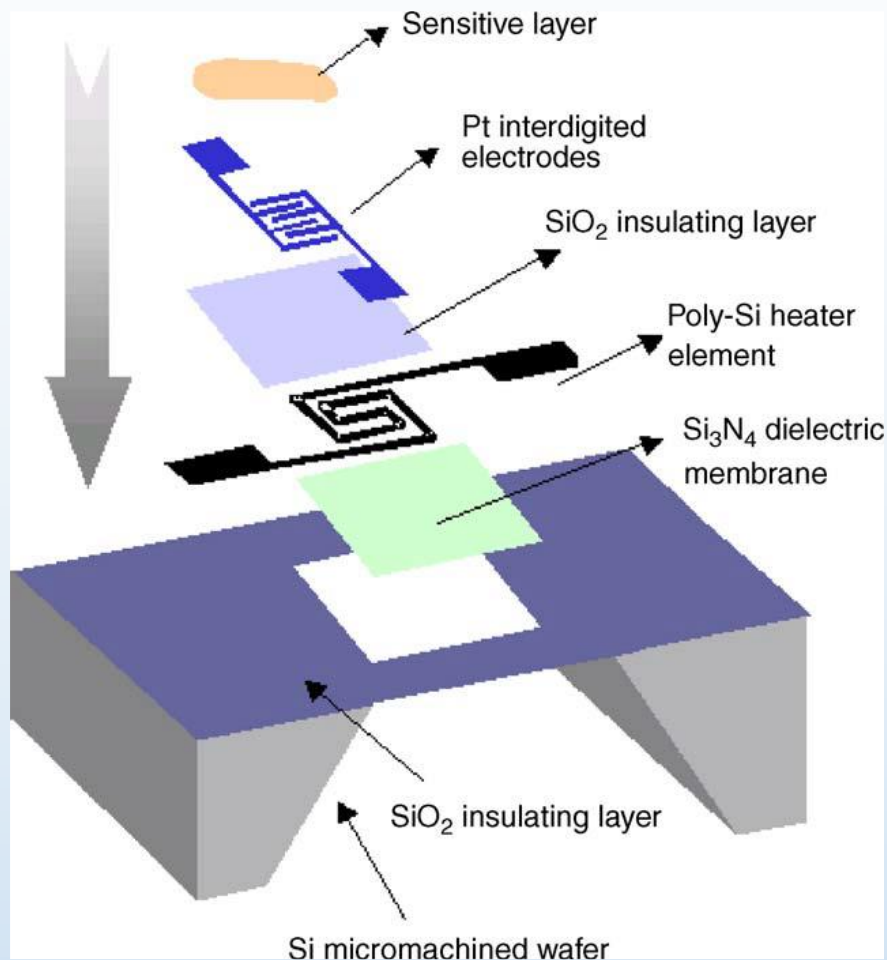


- **Target**      *NO<sub>2</sub>, O<sub>3</sub>, CO, VOCs, ...*
- **Cost**      *Materials, fabrication process, scale-up*
- **Power**      *Operation temperature*
- **Size**      *Miniaturization, micro- & nanofabrication*
- **Performance**      *Low pollutant concentrations, sensitivity, selectivity, response/recovery time*
- **Life-time**
- **Accuracy**
- **Stability**
- **Repeatability**

# 1. MOTIVATION (II)

## Metal Oxide Semiconductor (MOS) sensors

**MOS** sensors are produced by means of **costly technologies** (e.g. silicon processing, MEMS) and require **high power consumption** due to the high working temperature ( $>300\text{ }^{\circ}\text{C}$ ).

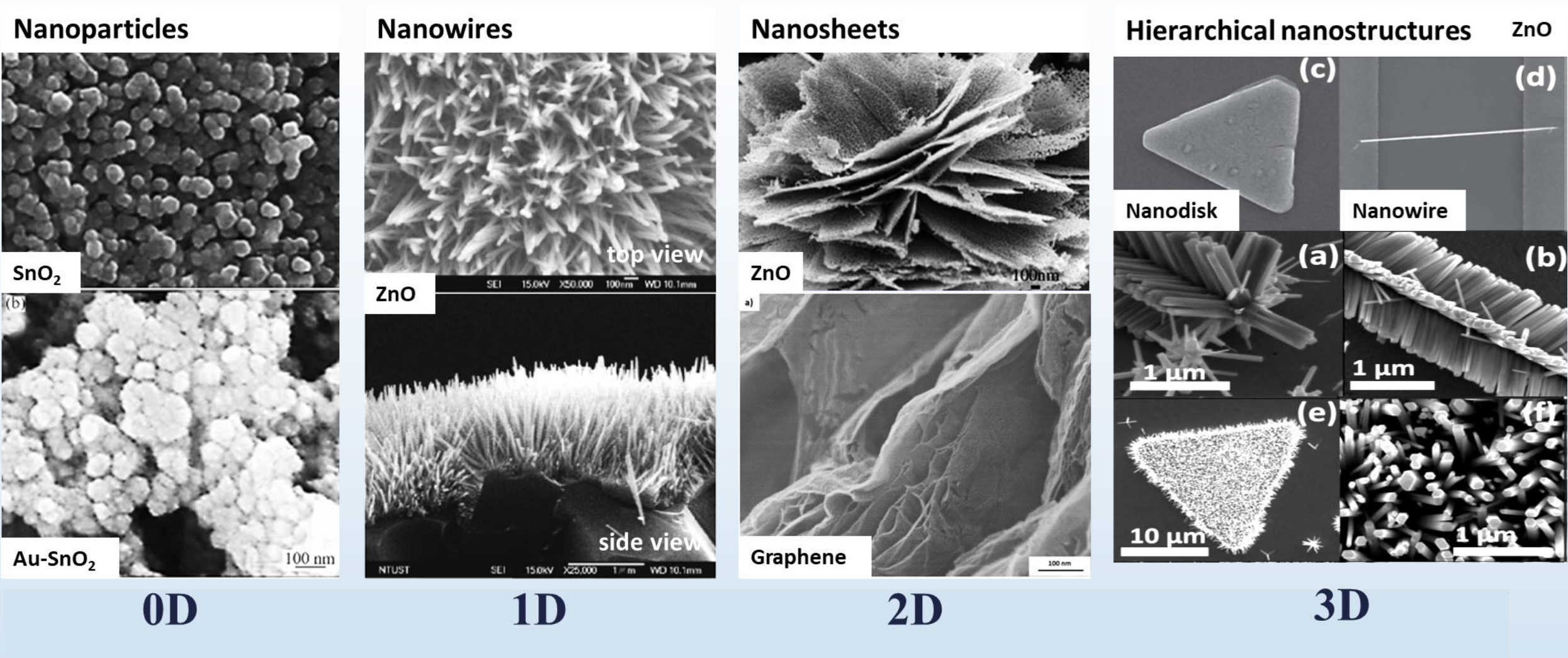


Response

$$Res = \frac{R_g - R_a}{R_a}$$

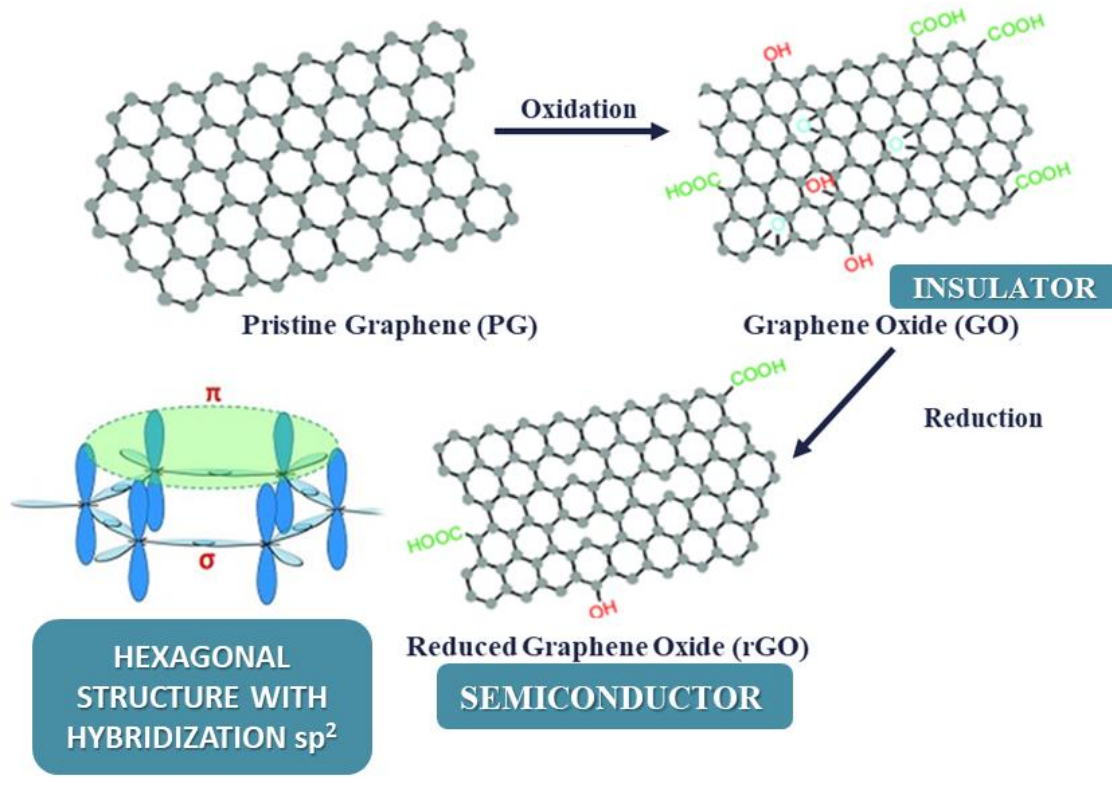
# 2.1. NANOSTRUCTURES

## Sensor based on nanostructured active layers (nanosensors)



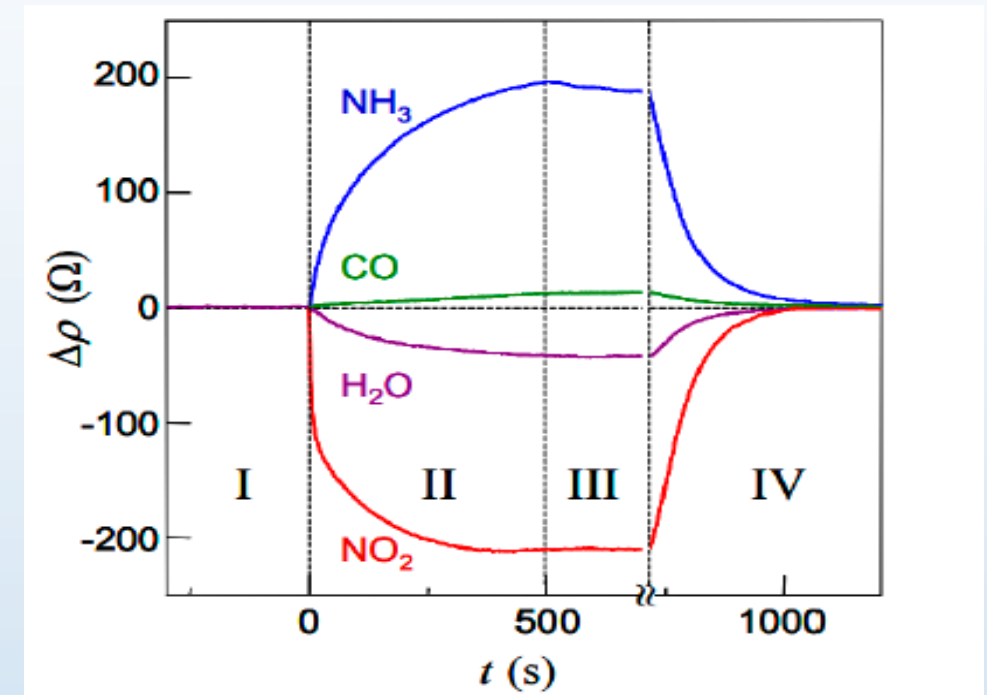
## 2.2. GRAPHENE

### Graphene materials (2D)



### Resistive gas sensors

Classification	Oxidizing gases	Reducing gases
n-type	Resistance ↑	Resistance ↓
p-type	Resistance ↓	Resistance ↑



- **PG** has high conductivity but is inert (lack of defects, oxygen groups) and needs to be functionalized (polymers, metals, metal oxides), costly non-scalable production
- **GO** has low conductivity but is very reactive (multiple oxygen groups)
- **rGO** has intermediate properties between PG and GO, sustainable mass production

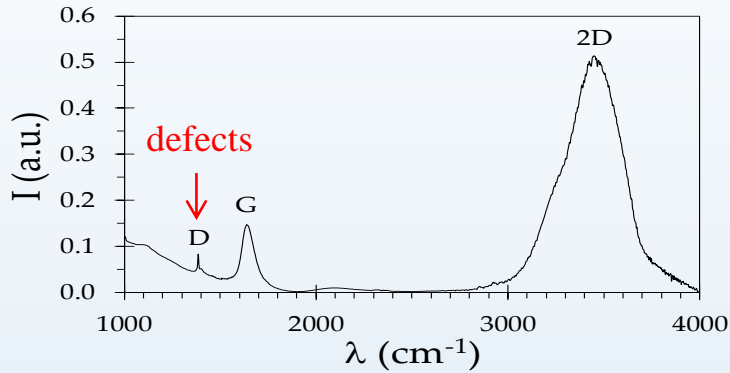
# 3.1. SENSOR MATERIALS

## Precursor suspension

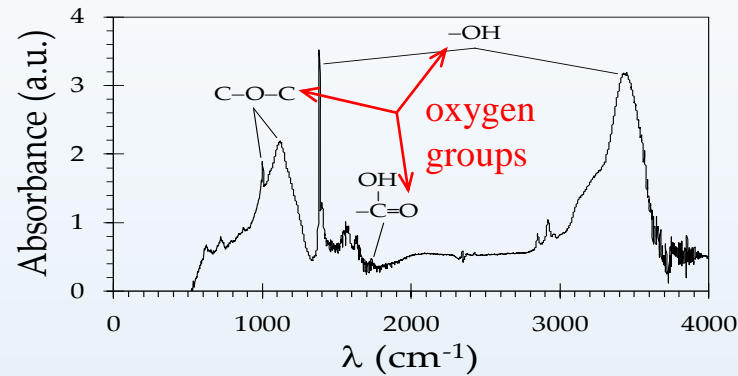
rGO in isopropyl alcohol (0.1mg/ml)

rGO powder (E800, Abalonyx AS, Norway)

Raman

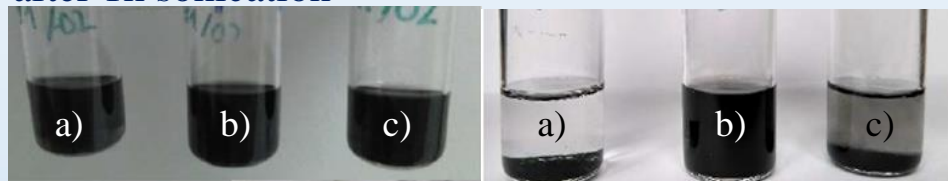


FTIR



after 1h sonication

after 24h at rest

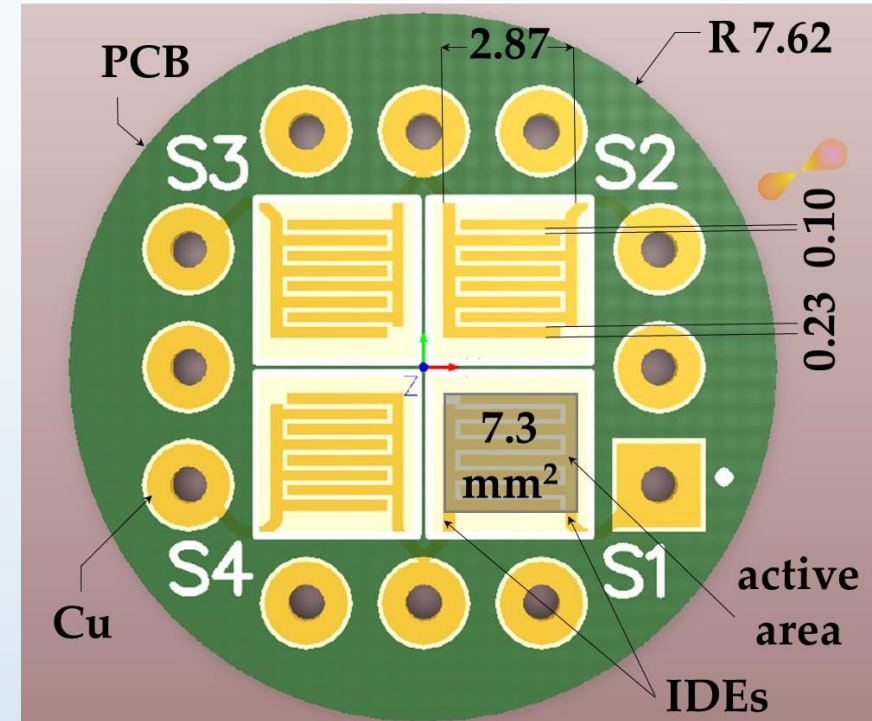


- a) acetone
- b) isopropyl alcohol
- c) ethanol

- Specific surface area 436 m<sup>2</sup>/gr
- Electrical conductivity 20 S/m
- Carbon-to-oxygen-ratio 35
- Number of layers 7

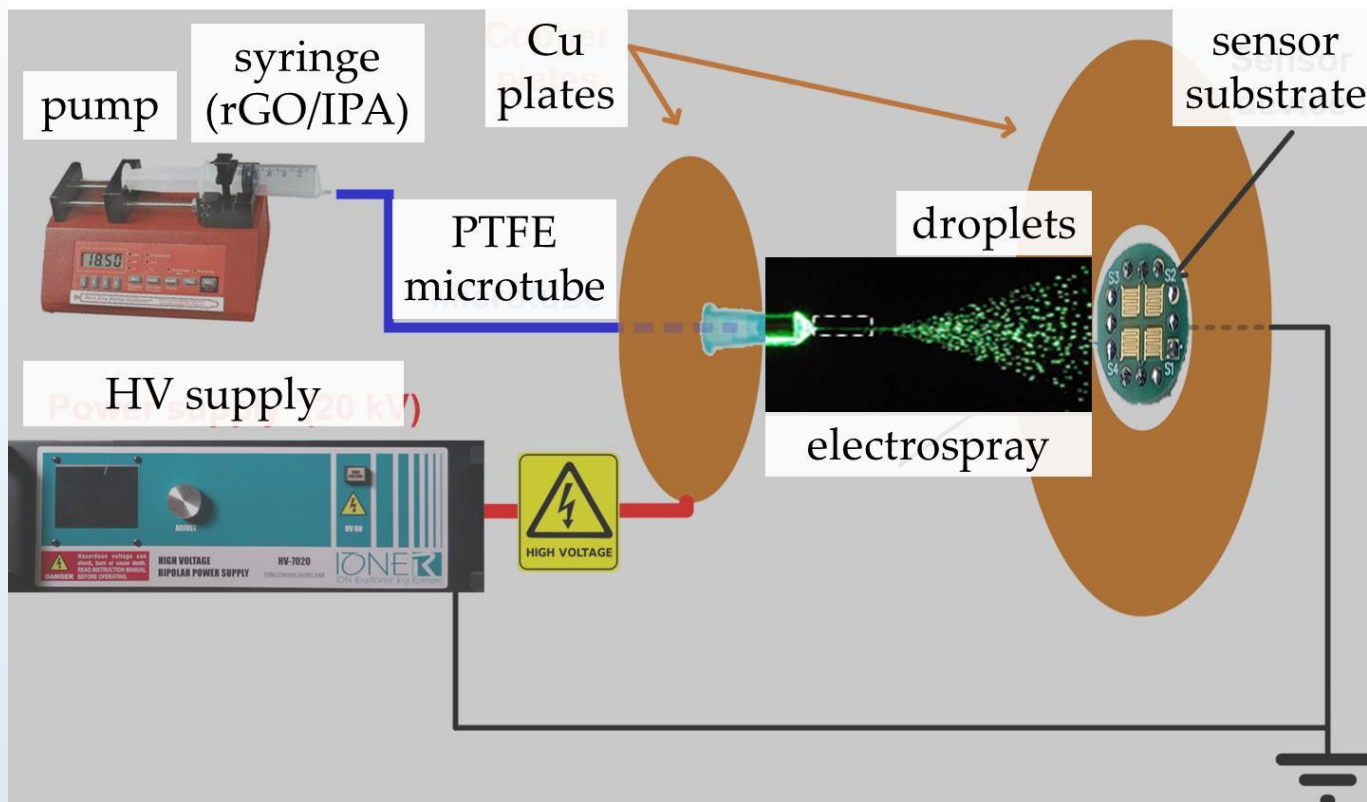
## Sensor substrate

Polymer (PCB) with printed interdigitated electrodes (Cu)



## 3.2. ELECTROSPRAY (I)

Sensors are prepared by **electrospray** of a rGO/IPA dispersion (0.1 mg/ml)



### Parameters

- **Needle inner/outer diameter** 0.3 / 0.5 mm
- **Distance needle-substrate** 5 - 30 mm
- **Voltage** 2 - 6 kV
- **Feed flowrate** 3 - 10  $\mu\text{L}/\text{min}$
- **Deposition time** 5 - 20 min

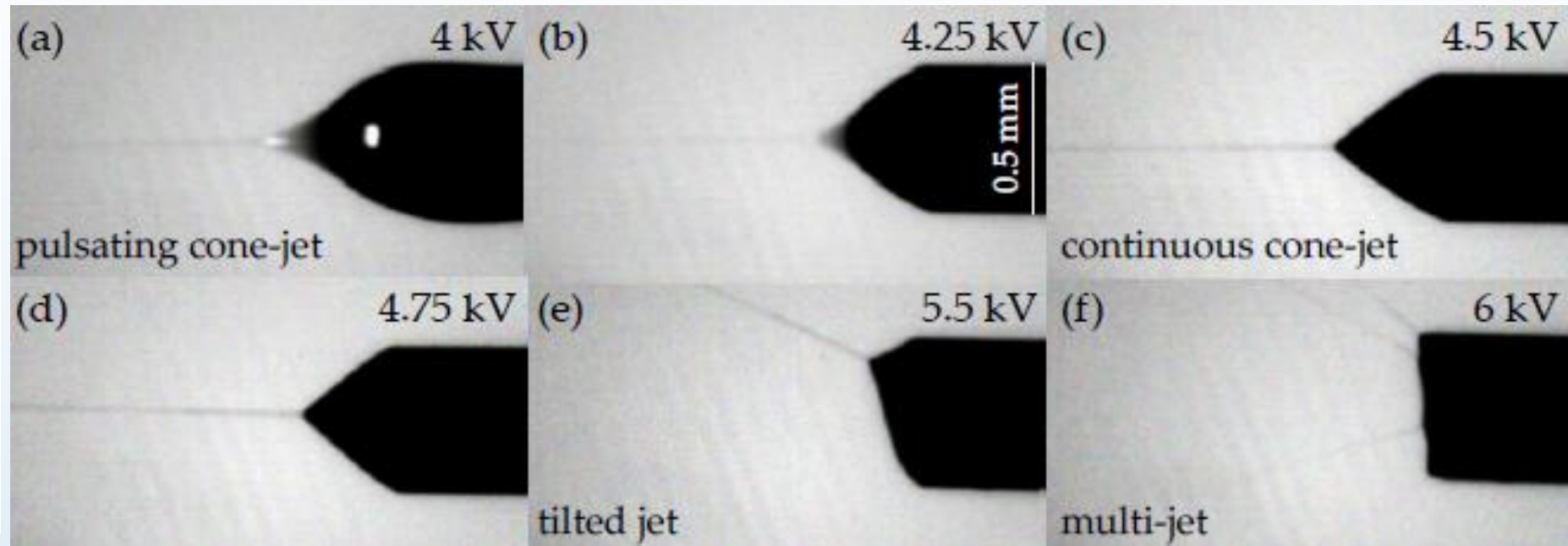
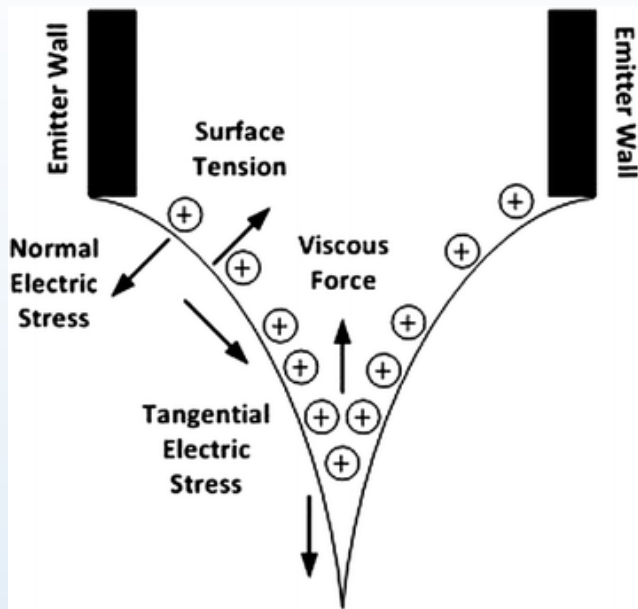
### Requirements

- **Stable dispersion** *Short deposition time*
- **Stable electrospay** *Optimal flowrate and voltage*
- **Solvent evaporation** *Highly volatile solvent, large distance*



## 3.2. ELECTROSPRAY (II)

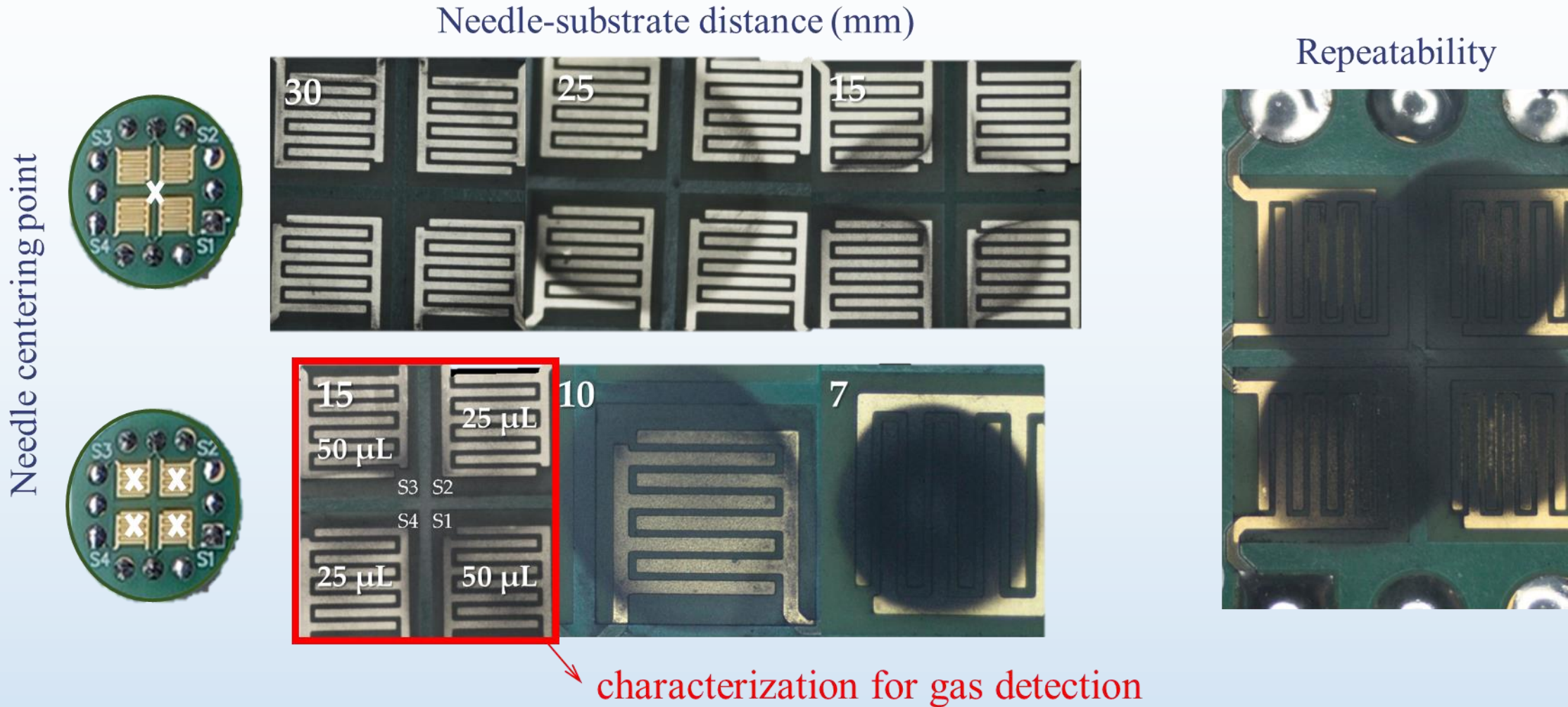
Electrospray regimes through increasing voltage:  
dripping, pulsed cone-jet, **continuous cone-jet**, tilted-jet and multi-jet .



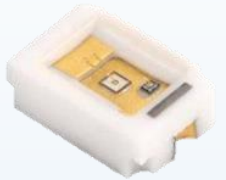
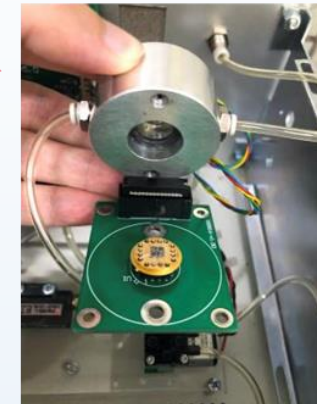
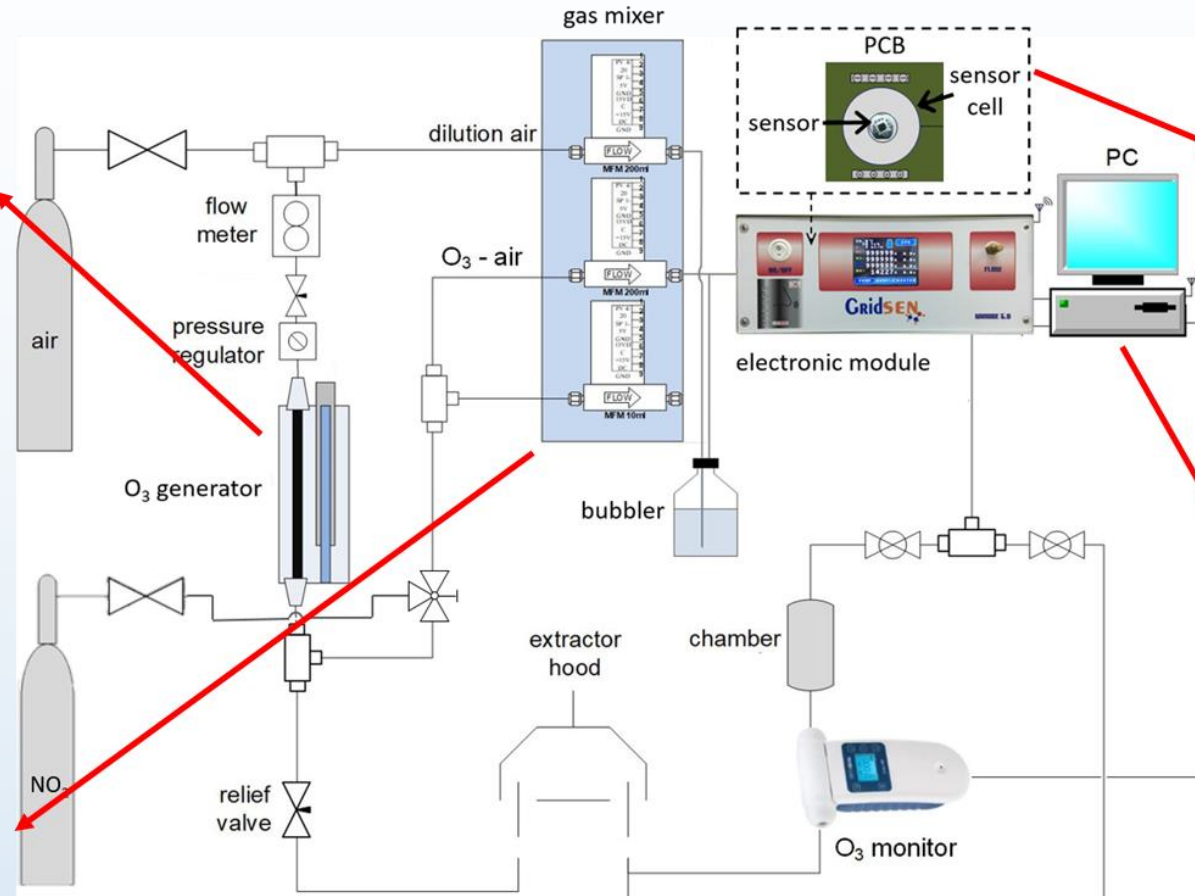
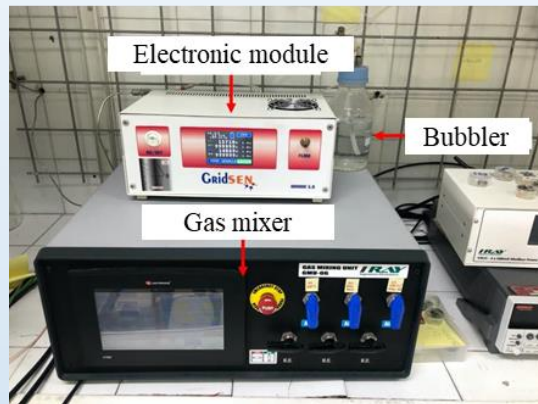
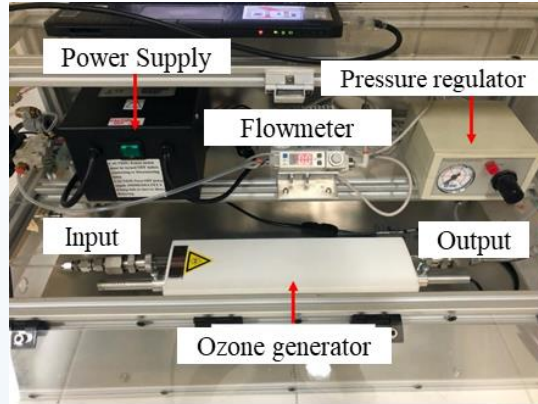
The liquid meniscus narrows and elongates under the action of the **surface tension** and the **electric field** force and at a critical voltage the **Taylor cone** is formed. With further increasing of the electric field, the cone becomes unstable and a very **thin jet** (small and thin compared with the capillary diameter) is emitted from the cone apex.

### 3.3. DEPOSITION PATTERN

**Circular spots of rather uniform deposits of rGO** are obtained in stable cone-jet mode. The diameter of the spot increases with the increasing needle-substrate distance

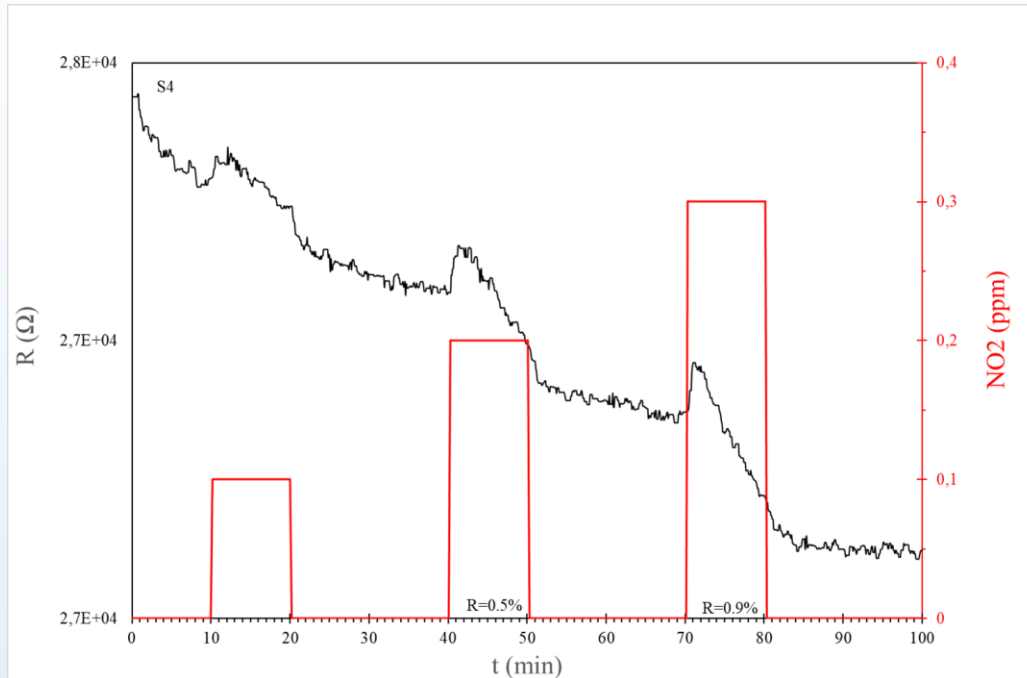


# 4. SENSOR CHARACTERIZATION



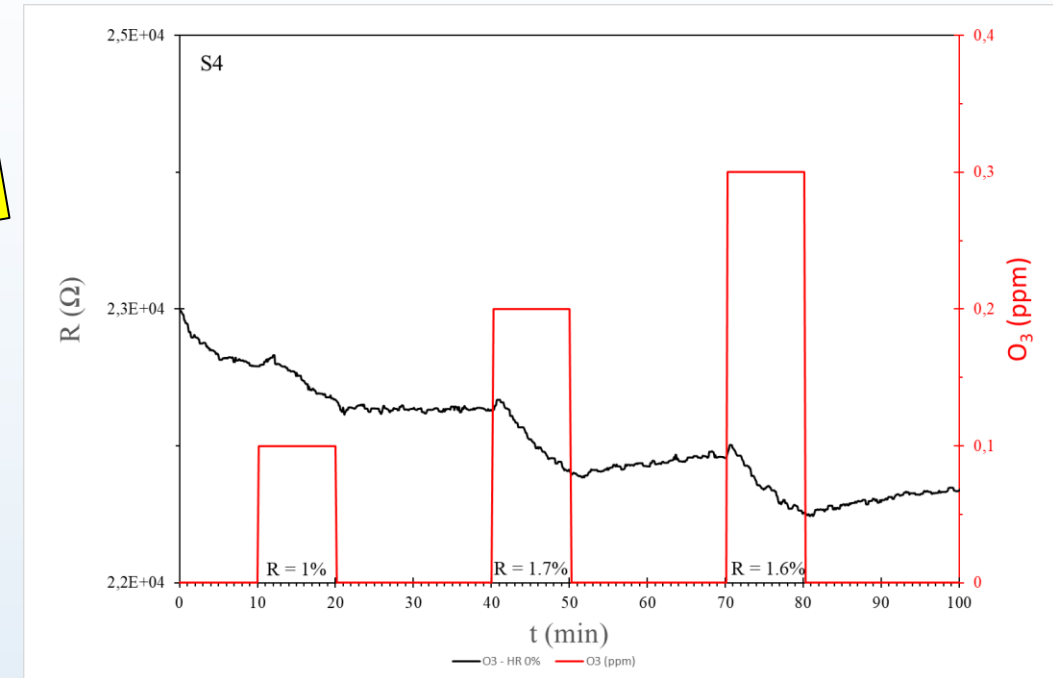
# 4.1. GAS DETECTION (NO<sub>2</sub>, O<sub>3</sub>, CO)

NO<sub>2</sub>



HR < 5%

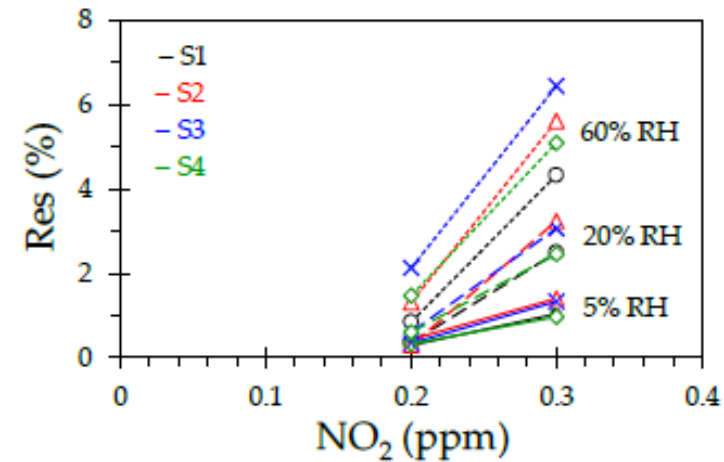
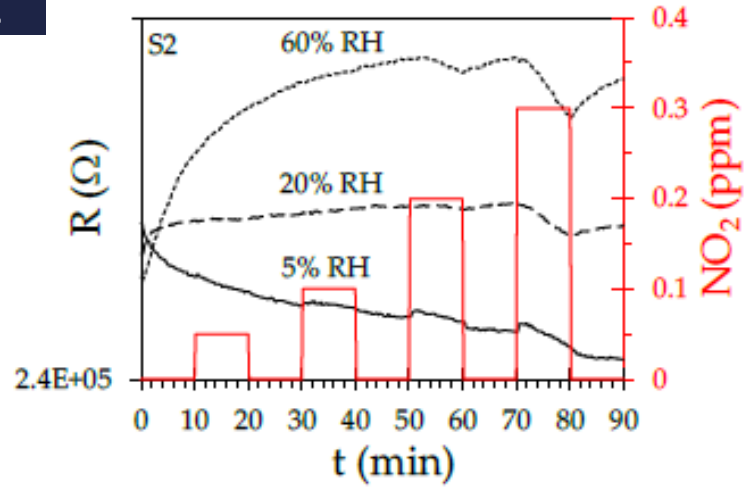
O<sub>3</sub>



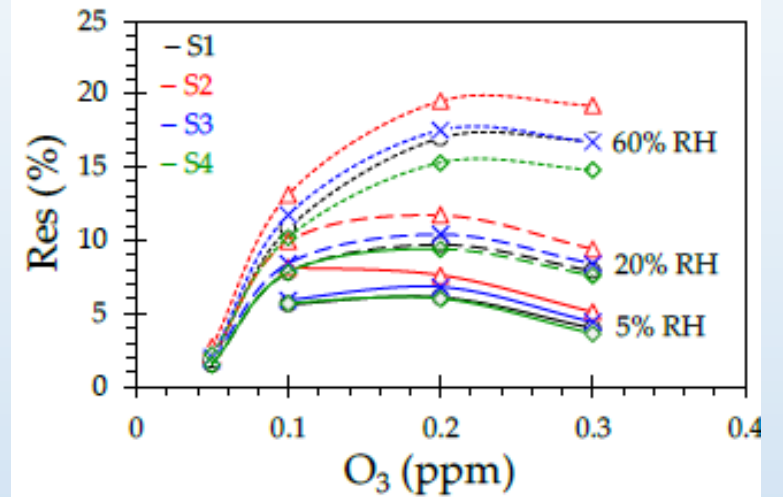
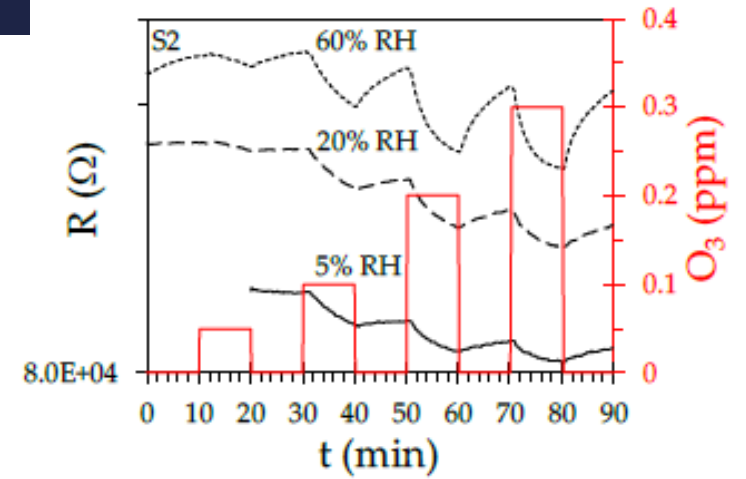
- P-type semiconductor
- Long recovery times
- Sensitivity O<sub>3</sub> > NO<sub>2</sub>
- No detection of CO (<5ppm)

# 4.2. HUMIDITY

**NO<sub>2</sub>**



**O<sub>3</sub>**

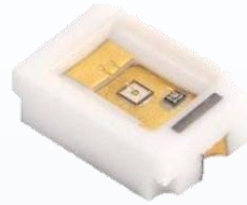


↑ Resistance  
↑ Response  
↓ Recovery time

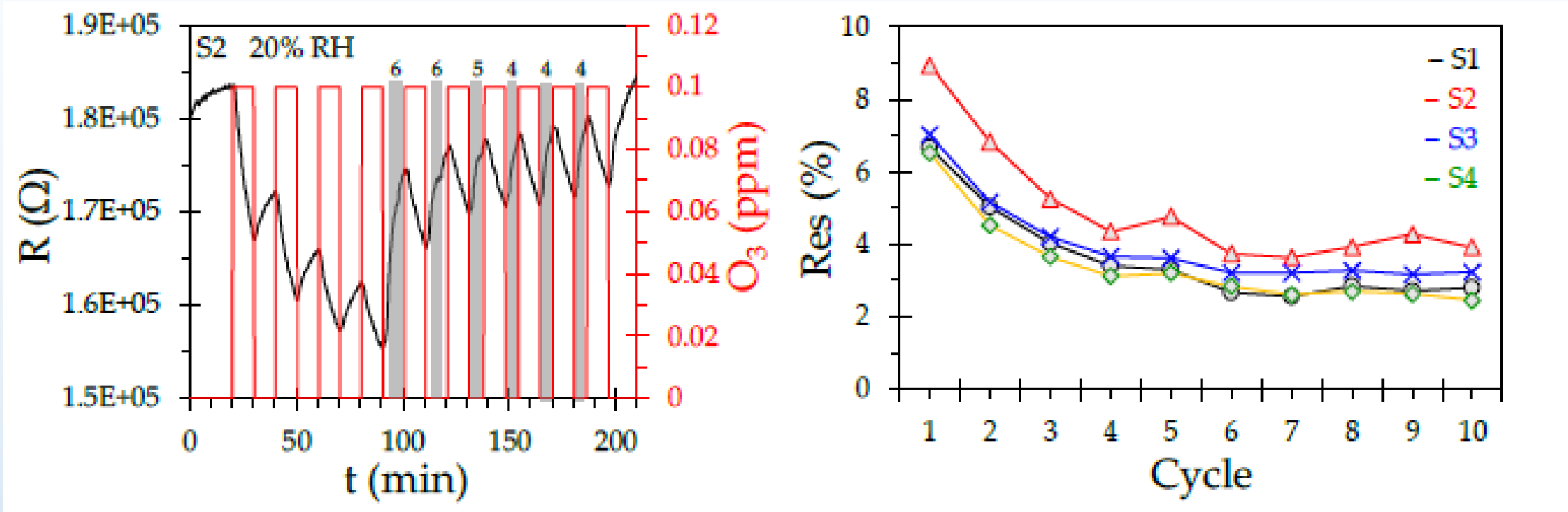
# 4.3. UV IRRADIATION

## UV-LED

- $\lambda_{peak} = 356 \text{ nm}$



UV irradiation → Active gas desorption



## 5. CONCLUSIONS (I)

Sensors based on electrospray printing of rGO layers have been characterised for low level detection of **NO<sub>2</sub>**, **O<sub>3</sub>** (< 300 ppb) and **CO** (< 5 ppm):

- Detection limits (**LOD**) for **O<sub>3</sub>** and **NO<sub>2</sub>** are **not sufficient** for air quality monitoring
- **Not CO sensitive** up to 5 ppm levels
- Sensors based on rGO **have very long recovery time** but it **decreases** with **increasing** air humidity
- **UV irradiation speeds-up gas desorption** at **room temperature**, **reducing recovery time**

## 5. CONCLUSIONS (II)

### Effects of electrospray parameters

- **Surface area** of rGO deposit **increases** with increasing **needle-substrate distance**
- **Homogeneous deposits** are obtained in a **stable cone-jet regime** and they are **reproducible**
- **Voltage** and **flowrate** determine the **spatial distribution** of rGO over the substrate
- **Deposition pattern** is very **sensitive to the applied voltage**. Small deviations from the voltage at stable cone-jet mode lead to drastic changes in the rGO spatial distribution



## 5. FUTURE WORK

- **Surfactants** or **dispersants** to optimize the long-term **dispersion of rGO**
- Effect of **rGO type** (C/O) on the sensor's detection sensitivity to air pollutants (NO<sub>2</sub>, O<sub>3</sub>, CO)
- **Doping rGO** for CO detection
- **Effect of UV light source parameters** (wavelength and intensity) on:
  - P/N-type performance of rGO
  - Sensitivity of rGO
  - Recovery time

# Thank you



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